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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|--|----------------------------|----------------------|-------------------------|------------------|
| 10/708,666 | 03/18/2004 | Chung-Chin Shih | 12423-US-PA-X-0P | 2665 |
| 31561 | 7590 05/06/2005 | | EXAM | NER |
| JIANQ CHYUN INTELLECTUAL PROPERTY OFFICE | | | OWENS, DOUGLAS W | |
| 7 FLOOR-1, ROOSEVELT | NO. 100 ROAD, SECTION 2 | | ART UNIT | PAPER NUMBER |
| TAIPEI, 10 | - | 2811 | | |
| TAIWAN | | | DATE MAILED: 05/06/2005 | 5 |

Please find below and/or attached an Office communication concerning this application or proceeding.

| • | | 51 |
|---|---|---|
| | Application No. | Applicant(s) |
| | 10/708,666 | SHIH, CHUNG-CHIN |
| Office Action Summary | Examiner | Art Unit |
| | Douglas W. Owens | 2811 |
| The MAILING DATE of this communication Period for Reply | appears on the cover sheet wi | th the correspondence address |
| A SHORTENED STATUTORY PERIOD FOR RETHE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFF after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, and a lift NO period for reply is specified above, the maximum statutory period for reply within the set or extended period for reply will, by standard patent term adjustment. See 37 CFR 1.704(b). | N. R 1.136(a). In no event, however, may a receive reply within the statutory minimum of thirty riod will apply and will expire SIX (6) MON atute, cause the application to become AB | reply be timely filed by (30) days will be considered timely. THS from the mailing date of this communication. BANDONED (35 U.S.C. § 133). |
| Status | | |
| 1) Responsive to communication(s) filed on 1 | 4 March 2005. | |
| 2a) This action is FINAL . 2b) ⊠ 7 | | |
| 3) Since this application is in condition for allo | wance except for formal matte | ers, prosecution as to the merits is |
| closed in accordance with the practice under | er <i>Ex parte Quayle</i> , 1935 C.D | . 11, 453 O.G. 213. |
| Disposition of Claims | | |
| 4) Claim(s) 1-22 is/are pending in the applicat | tion. | · |
| 4a) Of the above claim(s) is/are with | drawn from consideration. | |
| 5) Claim(s) is/are allowed. | | |
| 6) Claim(s) 1,2,5-8,10,12-17,19,21 and 22 is/a | are rejected. | |
| 7) Claim(s) 3,4,9,11,18 and 20 is/are objected | | |
| 8) Claim(s) are subject to restriction an | id/or election requirement. | |
| Application Papers | | |
| 9) The specification is objected to by the Exam | niner. | |
| 10)⊠ The drawing(s) filed on 18 March 2004 is/ar | re: a)⊠ accepted or b)□ obj | ected to by the Examiner. |
| Applicant may not request that any objection to | the drawing(s) be held in abeyan | ice. See 37 CFR 1.85(a). |
| Replacement drawing sheet(s) including the cor | | |
| 11) The oath or declaration is objected to by the | e Examiner. Note the attached | J Office Action or form PTO-152. |
| Priority under 35 U.S.C. § 119 | | |
| 12) Acknowledgment is made of a claim for fore | eign priority under 35 U.S.C. § | 3 119(a)-(d) or (f). |
| a) All b) Some * c) None of: | | |
| 1. Certified copies of the priority docum | ents have been received. | |
| 2. Certified copies of the priority docum | ents have been received in A | pplication No |
| 3. Copies of the certified copies of the p | oriority documents have been | received in this National Stage |
| application from the International Bui | , , , , | |
| * See the attached detailed Office action for a | list of the certified copies not | received. |
| Attachment(e) | | |
| Attachment(s) 1) Notice of References Cited (PTO-892) | 4) T Interview S | Summary (PTO-413) |
| 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) | Paper No(s | s)/Mail Date |
| 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB Paper No(s)/Mail Date | 5) Notice of Ir 6) Other: | nformal Patent Application (PTO-152) |

U.S. Patent and Trademark Office PTOL-326 (Rev. 1-04)

Art Unit: 2811

DETAILED ACTION

Election/Restrictions

1. Applicant's election without traverse of the invention of group I, claims 1 - 22 in the reply filed on March 15, 2005 is acknowledged.

Specification

2. The title of the invention is not descriptive. A new title is required that is clearly indicative of the invention to which the claims are directed.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 4. Claims 1, 2 6, 8, 10, 12 17, 19, 21 and 22 are rejected under 35
 U.S.C. 102(e) as being anticipated by US Patent No. 6,835,987 to Yaegashi.

Regarding claims 1, 13, 17 and 21, Yaegashi teaches a memory device (Figs. 6 – 11 and 18, for example), comprising:

a plurality of isolation regions (17) disposed in a substrate (1), defining a plurality of active regions (16) in the substrate;

a plurality of pairs of word lines (14, in gate stacks 18) substantially parallel to one another, disposed on and in a direction vertical to the plurality of isolation structures

Application/Control Number: 10/708,666

Art Unit: 2811

and the plurality of active regions, wherein the active regions that are covered by the plurality of pairs of word lines are defined as a plurality of first channel regions;

a plurality of first gates (11) disposed on the plurality of the first channel regions and between the substrate and the plurality of word lines;

a plurality of pairs of source lines (14 of gate stacks 19), substantially parallel to the plurality of pairs of word lines, each pair of source lines being between each pair of word lines, wherein the plurality of source lines are disposed in a direction vertical to the plurality of isolation structures and the plurality of active regions, and wherein the active regions that are covered by the plurality of pairs of source lines are defined as a plurality of second channel regions;

a plurality of second gates (11), in strip shapes, disposed on an in a direction vertical to the plurality of isolation structures and the plurality of the active regions and between the substrate and the plurality of source lines;

a first dielectric layer (5) between the plurality of active regions and the plurality of first gates, and between the plurality of active regions and the plurality of second gates;

a second dielectric layer (13) between the plurality of word lines and the plurality of first gates and between the plurality of sources lines and the plurality of second gates;

a third dielectric layer (25) disposed over the substrate and covering the plurality of word lines and the plurality of source lines;

Application/Control Number: 10/708,666

Art Unit: 2811

a plurality of source/drain regions (23, 24) disposed in the active regions beside the first gates and the second gates;

a plurality of source line contacts (Fig. 18; Col. 14, lines 31 - 40), through the third dielectric layer, connecting to the source/drain regions that are between each pair of the source lines and electrically connecting to at least one of each pair of source lines; and

a plurality of insulating layers (20) disposed between the plurality of the second gates and the plurality of the source line contacts.

Regarding claim 2, Yaegashi teaches a memory device, wherein the plurality of isolation structures are disposed in strip shapes, thus defining the active regions in strip shapes.

Regarding claims 5 and 15, Yaegashi teaches a memory device, wherein the material of the source lines is the same as that of the word lines (Col. 11, lines 60 and 61).

Regarding claims 6 and 16, Yaegashi teaches a memory device, wherein the material of the source lines and word lines include polysilicon and metal silicide (Col. 11, lines 60 and 61).

Regarding claim 8, Yaegashi teaches a memory device, wherein each source line contact connects to one source/drain region and electrically connects to at least one of each pair of the source lines.

Regarding claims 10 and 19, Yaegashi teaches a memory device, wherein each source line contact is a self-aligned contact.

Regarding claims 12 and 22, Yaegashi teaches a memory device, wherein the memory device is a flash memory device, the first gate is a floating gate and the second gate is a select gate.

Regarding claim 14, Yaegashi teaches a memory device, wherein a height and a contour of the source lines are substantially equivalent to a height and a contour of the word lines.

Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 6. Claim 7 is rejected under 35 U.S.C. 103(a) as being unpatentable over Yaegashi. Yaegashi teaches a memory device, further comprising a plurality of spacers (29, 33). Yaegashi does not teach that the thickness of the insulating layer between the second gate and the source line contact is smaller than half of a thickness of the spacer. The thickness of the insulation layer between a floating gate and control gate is a known result effective variable that is subject to optimization. It would have been obvious to one of ordinary skill in the art to find the optimal thickness thereof through routine experimentation (In re Antonie, 559 F.2d 618, 195 USPQ 6 (CCPA 1977)).

Art Unit: 2811

Allowable Subject Matter

7. Claims 3, 4, 9, 11, 18 and 20 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Douglas W. Owens whose telephone number is 571-272-1662. The examiner can normally be reached on Monday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C. Lee can be reached on 571-272-1732. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Douglas W Owens

Douglos L. Oman

Examiner Art Unit 2811